

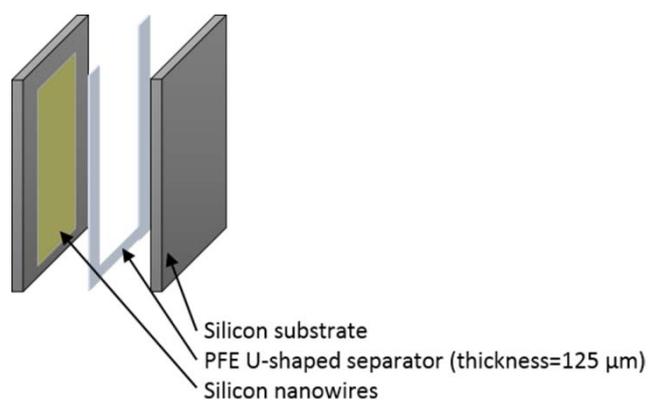
## Supporting Information

### Solder-Reflow Resistant Solid-State Micro-Supercapacitor based on Ionogels

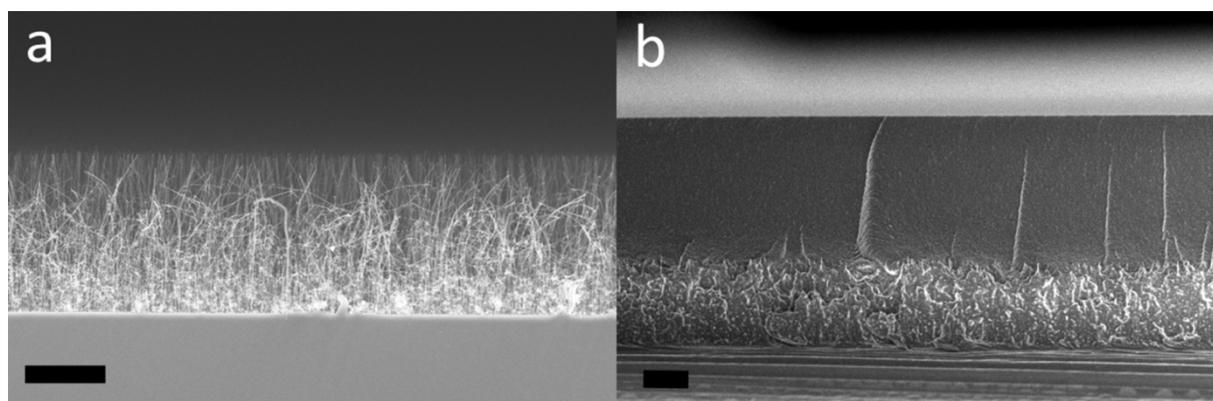
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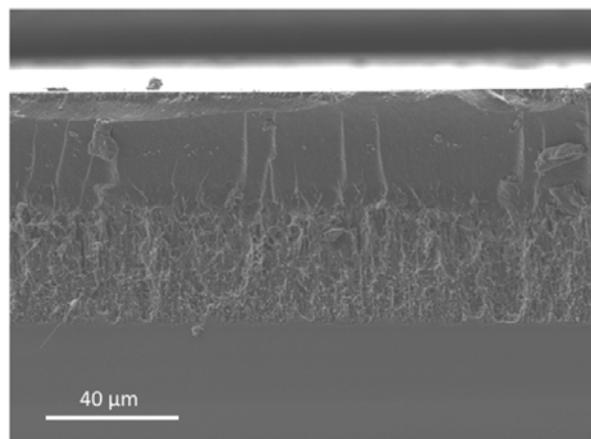
**Fig. S1** Photography of a TMOS-DMDMS ionogel flexible membrane.



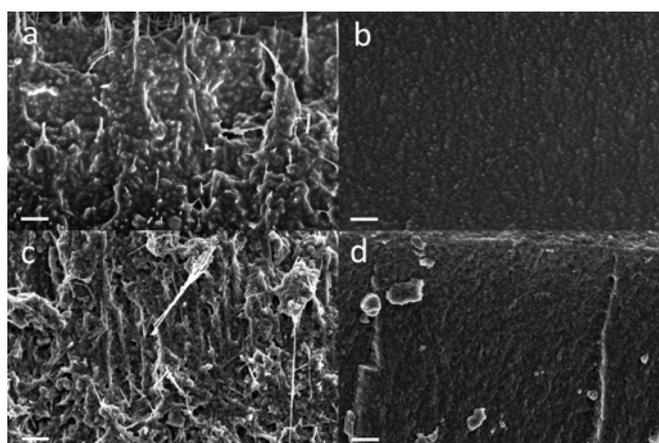
**Fig. S2** Schematic representation of the  $\mu$ SC with a PFE mechanical separator to control the non-confined ionic liquid thickness between the two SiNW electrodes.



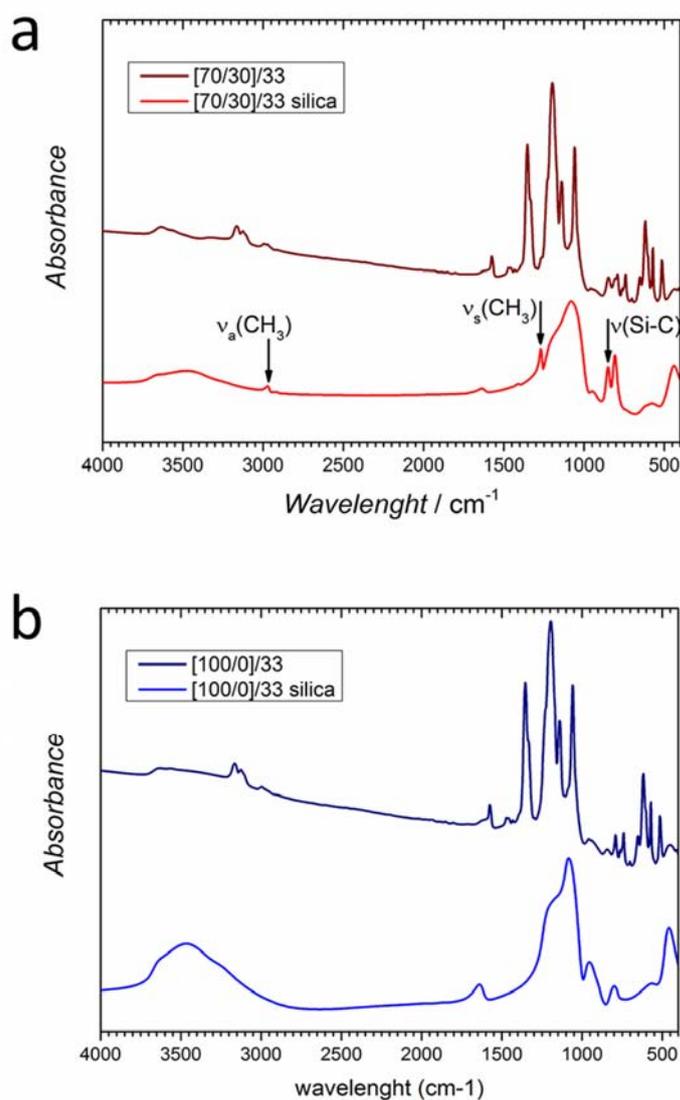
**Fig. S3** SEM cross-section observation of 20  $\mu$ m SiNWs without ionogel (a) and with [70/30]/33 ionogel (b) (scale bar=10  $\mu$ m).



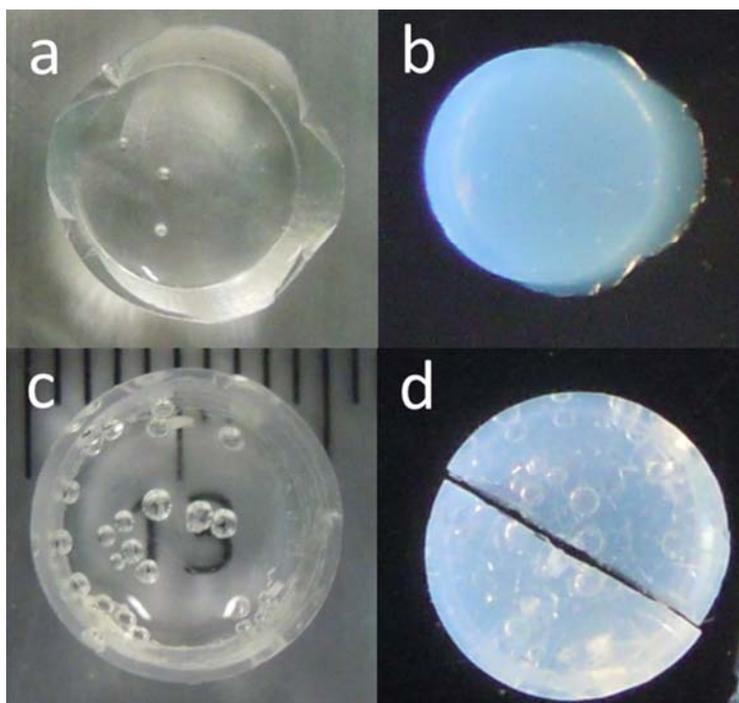
**Fig. S4** SEM cross-section image of the zone used for EDX mapping of the ([70/30]/33 ionogel with the 40  $\mu\text{m}$  SiNW electrode)



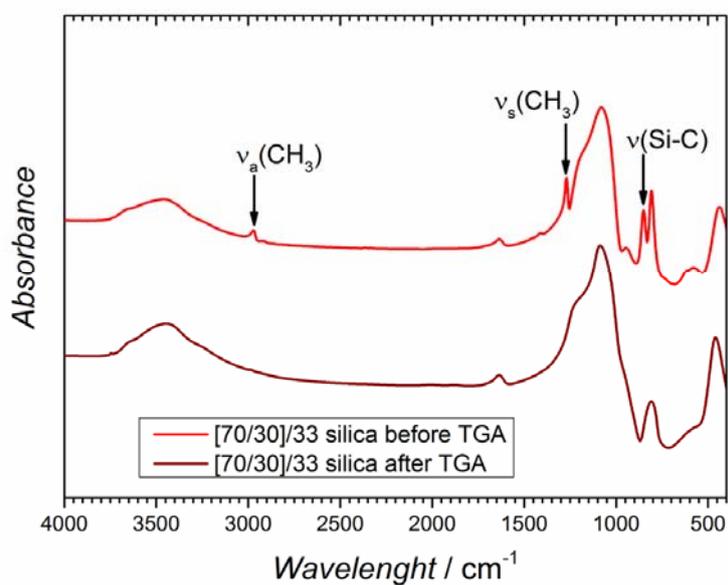
**Fig. S5** SEM images of the [70/30]/33 ionogel within 20  $\mu\text{m}$  SiNWs (a), above 20  $\mu\text{m}$  SiNWs (b), within 40  $\mu\text{m}$  SiNWs (c) and above 40  $\mu\text{m}$  SiNWs (d) (scale bar=2  $\mu\text{m}$ ).



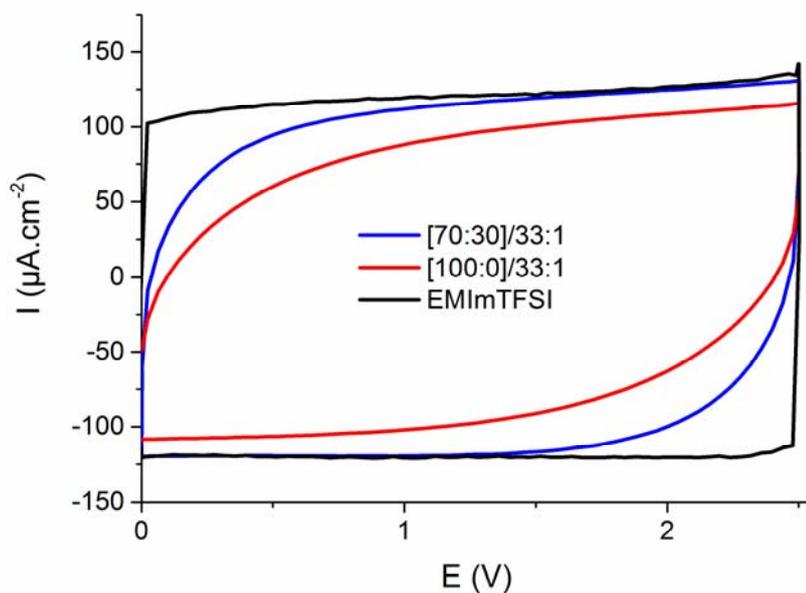
**Fig. S6** (a) FTIR spectrum of the [70/30]/33 ionogel and silica host networks from [70/30]/33 after Soxhlet extraction of the EMIm TFSI. Absorbance bands due to the methyl groups in the [70/30]/33 are marked by the black arrows. (b) FTIR spectrum of the [100/0]/33 ionogel and silica host networks from [100/0]/33 after Soxhlet extraction of the EMIm TFSI.



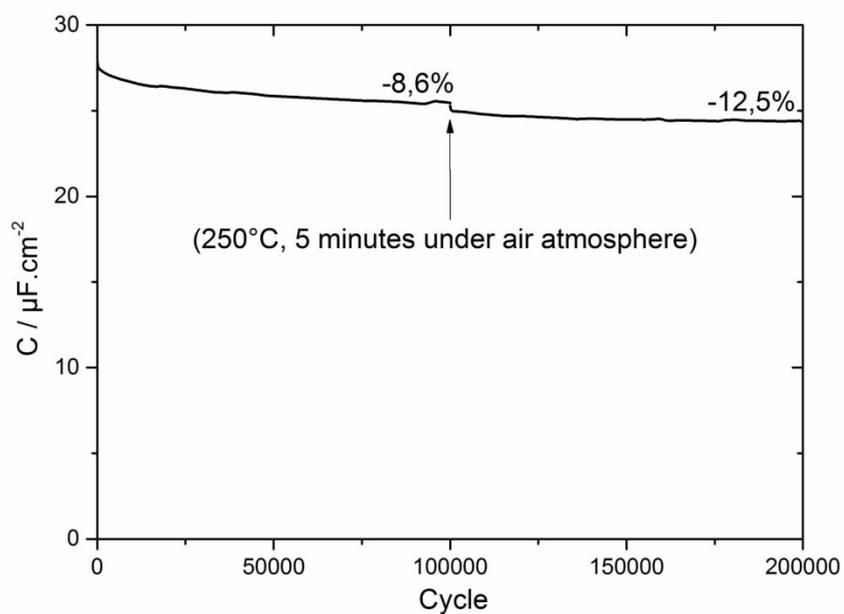
**Fig. S7** The [100/0]/33 ionogel pellet before (a) and after (b) EMIm TFSI extraction and drying in a Buchi (60 °C, under vacuum, 18 h). The [70/30]/33 ionogel pellet before (c) and after (d) liquid extraction and drying in a Buchi (60 °C, under vacuum, 18 h). The pellets' diameters are around 8-9 mm.



**Fig. S8** FTIR spectrum of the [70/30]/33 host network, after Soxhlet extraction of the EMIm TFSI, before (a) and after (b) TGA analysis under an O<sub>2</sub> atmosphere at 2 °C.min<sup>-1</sup> up to 800 °C. Absorbance bands due to the presence of methyl groups are marked by the black arrows.



**Fig. S9** Cyclic voltammetry (1 V.s<sup>-1</sup>) of micro-supercapacitors ( $\mu$ SCs) with non-confined EMIm TFSI, [100/0]/33 and [70/30]/33 electrolytes, using SiNW electrodes with lengths of 20  $\mu$ m.



**Fig. S10** GCPL (20  $\mu$ A between 0 V and 3 V) for 20  $\mu$ m SiNWs with [70/30]/33 ionogel : 100000 cycles before solder reflow and 100000 cycles after solder reflow.

t= 0 sec



t= 15 sec



t= 30 sec



**Fig. S11** Re-absorption, after annealing at 250 °C for 5 minutes of the [70/30]/33 ionogel, of the IL, subsequent to its thermal expansion : photographs taken immediately (0 s) at the exit of the oven, and after 15 s and 30s.